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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/807,139	03/24/2004	Jaekwang Choi	2557-000215/US	2759
30593 7590 04/05/2007 HARNESS, DICKEY & PIERCE, P.L.C. EXAMI				INER
P.O. BOX 8910	·	GOUDREAU, GEORGE A		
RESTON, VA 20195			ART UNIT	PAPER NUMBER
			1763	
		·		<u> </u>
SHORTENED STATUTORY	Y PERIOD OF RESPONSE	MAIL DATE	DELIVERY MODE	
3 MON	NTHS	04/05/2007	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

If NO period for reply is specified above, the maximum statutory period will apply and will expire 6 MONTHS from the mailing date of this communication.

	Application No.	Applicant(s)	
	10/807,139	CHOI ET AL.	
Office Action Summary	Examiner	Art Unit	
·	George A. Goudreau	1763	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with	the correspondence ac	ddress
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNIC, 36(a). In no event, however, may a repril apply and will expire SIX (6) MONT, cause the application to become ABA	ATION. bly be timely filed HS from the mailing date of this of the control of t	
Status	•		
1) Responsive to communication(s) filed on 26 December 2a) This action is FINAL. 2b) This 3) Since this application is in condition for alloware closed in accordance with the practice under Expression 1.	action is non-final. nce except for formal matte		e merits is
Disposition of Claims			
4) Claim(s) 1-3,5-11,14-17 and 28-31 is/are pend 4a) Of the above claim(s) is/are withdraw 5) Claim(s) 1-3,11,14-17 and 28-31 is/are allowed 6) Claim(s) 5-10 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or	vn from consideration. d.		
Application Papers			
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) acce Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex	epted or b) objected to b drawing(s) be held in abeyand ion is required if the drawing(s	ce. See 37 CFR 1.85(a). s) is objected to. See 37 C	
Priority under 35 U.S.C. § 119			
a) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the priority application from the International Bureau	s have been received. s have been received in Ap rify documents have been i u (PCT Rule 17.2(a)).	oplication No received in this Nationa	al Stage
* See the attached detailed Office action for a list	of the certified copies not r	eceived.	Λ
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date	Paper No(s)	GEOFIGE GOUDRE PRIMARY EXAMINE 3-07(Jummary (PTO-413) Jummary (PT	udrean AU ER

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1. Claims 1-3, 11, 14-17, and 28-31 are allowed.

2. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claim 5 is rejected under 35 U.S.C. 102(b) as being anticipated
 Mizutari et. al. (JP 2001-110,760).

Mizutari et. al. disclose a process for cmp polishing a Si wafer with a cmp slurry with a pH of (8-12) which is comprised of the following components:

-H2O,

-silica abrasive particle,

-a first non-ionic surfactant of the type which is claimed by the applicant with a MW of (1,000-10,000), and

-a second surfactant

They further disclose that the first ionic surfactant of the type, which is claimed by the applicant, may have two different molecular structures. Type I has a structure comprised of HO-(PO)a-(EO)b-(PO)c-H where a, b, c have values of at least 1. This corresponds to the structure recited by applicant for formula IV. Type II has a structure comprised of HO-(EO)d-(PO)e-(EO)f-H where d, e, and f have values of at least 1. This corresponds to the structure recited by applicant for formula III. They further disclose that the type I surfactant may be used together in the same cmp slurry as the type II surfactant. Further, they disclose

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that (a+c)=(10-100), and b=(2-500). Also, they disclose that (d+f)=(10-100), and e=(2-500). This is discussed specifically in the abstract; and discussed in general on pages 1-6.

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 6. Claims 6-10 are rejected under 35 U.S.C. 103(a) as being unpatentable over reference as applied in paragraph 3 above.

The reference as applied in paragraph 3 above fail to specifically disclose the following aspects of applicant's claimed invention:

-the specific cmp polishing process parameters, which are claimed by the applicant

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It would have been prima facie obvious to employ any of a variety of different processing parameters in the cmp polishing process, which is taught above. These are all well-known variables in the cmp polishing art, which are known to affect both the rate and the quality of the cmp polishing process. Further, the selection of particular values for these variables would not necessitate any undo experimentation, which would have been indicative of unexpected results.

Alternatively, it would have been obvious to one skilled in the art to employ the specific cmp polishing parameters which are claimed by the applicant in the cmp polishing process which is taught above based upon In re Aller as cited below.

Where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation.≅ In re Aller, 220 F. 2d 454, 105 USPQ 233, 235 (CCPA).

Further, all of the specific process parameters, which are claimed by the applicant, are results affective variables whose values are known to affect both the rate, and the quality of the cmp polishing process.

7. Claims 6-10 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

-In the claims, applicant should replace the claim language "from a group consisting of" with "from the group consisting of" in order to be proper Markush claim language. (i.e.-Applicant should carefully check every claim with a Markush group in it in this regard.)

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8. Applicant's arguments with respect to claims of record have been considered but are most in view of the new ground(s) of rejection.

9. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, **THIS ACTION IS MADE FINAL**. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication should be directed to examiner
 George A. Goudreau at telephone number (571)-272-1434.

George A. Goudreai Primary Examiner

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